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## Ozone Formation from Illuminated Titanium Dioxide Surfaces

María Eugenia Monge,<sup>†</sup> Christian George,<sup>\*,†</sup> Barbara D'Anna,<sup>†</sup> Jean-François Doussin,<sup>‡</sup> Adla Jammoul,<sup>‡</sup> Junnan Wang,<sup>‡</sup> Grégory Eyglunent,<sup>§</sup> Géraldine Solignac,<sup>§</sup> Véronique Daële,<sup>§</sup> and Abdelwahid Mellouki<sup>§</sup>

IRCELYON, Institut de recherches sur la catalyse et l'environnement de Lyon, CNRS UMR 5256, Université Lyon 1. 2, Av. Albert Einstein, F-69626 Villeurbanne Cedex, France, LISA Laboratoire interuniversitaire des systèmes atmosphériques, Universités Paris Est Créteil et Paris Diderot, CNRS UMR 7583, 61 Av. du Général de Gaulle, 94010 Créteil, France, and ICARE Institut de Combustion, Aérothermique, Réactivité et Environnement, CNRS - UPR3021, 1C, Av. de la recherche scientifique, 45071 Orléans Cedex 02, France

Received March 5, 2010; E-mail: christian.george@ircelyon.univ-lyon1.fr

Titanium dioxide,  $TiO_2$ , is used in a variety of remediation processes due to its favorable physical, chemical, and photocatalytic properties. <sup>1–3</sup> Possible removal of  $NO_x$  by means of depolluting surfaces containing  $TiO_2$  has been previously reported. <sup>4–13</sup> Other recent studies <sup>14–17</sup> show that this process converts  $NO_2$  to  $HNO_2$  producing also  $H_2O_2$  and  $H_2O_3$  and nitrate anions <sup>9,18–22</sup> which are then involved in a renoxification process. <sup>23</sup> Similarly, the photochemistry of adsorbed nitrate on aluminum oxide has been proven to produce  $HO_3$ ,  $HO_3$ , and  $HO_3$ 0. However, the formation of non-nitrogen containing products in the  $HO_3$  reaction with illuminated  $HO_3$  surfaces has been largely unexplored.

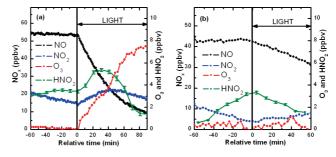
Herein, we report the first investigation of such products from  ${\rm TiO_2}$  coated glasses exposed to nitrogen oxides (NO<sub>x</sub>) in two simulation chambers using both artificial and natural illumination and from irradiated  ${\rm TiO_2/KNO_3}$  films using a coated-wall flow tube reactor. These studies demonstrate the formation of ozone from  ${\rm TiO_2}$  surfaces containing nitrate anions.

Chamber simulation experiments are performed in two different chambers (i) a stainless steel Multiphase Atmospheric Experimental Simulation Chamber (CESAM) equipped with artificial irradiation and (ii) a Teflon outdoor chamber (see Supporting Information for experimental details and Figures S1–S3). After introduction of synthetic air and NO into the CESAM chamber, the concentrations of NO, NO<sub>2</sub>, HNO<sub>2</sub>, and O<sub>3</sub> are monitored in the dark for 1 h. Then, the artificial illumination is turned on, and the gas mixture is again monitored for typically 90 min.

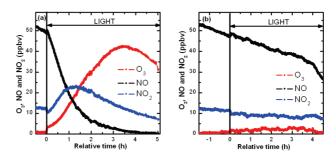
A similar procedure is adopted for the experiments conducted in the Teflon outdoor chamber using natural illumination. In the latter, known amounts of NO and NO<sub>2</sub> are injected after flushing with dry purified air, and the NO, NO<sub>2</sub>, and O<sub>3</sub> concentrations are monitored for 30 min in the dark. The reactor is then exposed to natural light, and the gas mixture composition is monitored for 4 h. The results for a TiO<sub>2</sub> coated glass and for a standard glass studied with the CESAM and the outdoor chamber are displayed in Figures 1 and 2, respectively. An example of the NO, NO<sub>2</sub>, and O<sub>3</sub> concentration—time profiles obtained in the absence of any surface using the outdoor chamber is shown in Figure S4.

Despite the different time scales and the chamber characteristics (i.e., irradiation type and chambers building material) the observed trace gas evolution is similar over a  ${\rm TiO_2}$  coated glass. In agreement with previous studies,  $^{26}$  NO uptake on the  ${\rm TiO_2}$  coated glass is enhanced under irradiation increasing with time in both experiments. The NO<sub>2</sub> concentration profile exhibits a maximum under illumina-

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**Figure 1.** NO, NO<sub>2</sub>, HNO<sub>2</sub>, and O<sub>3</sub> concentration profiles over (a) a  $TiO_2$  coated glass and (b) a standard glass ( $TiO_2$  free) in the CESAM chamber. The vertical line indicates the start of the irradiation.



**Figure 2.** NO,  $NO_2$ , and  $O_3$  profiles under natural irradiation in the presence of (a) a  $TiO_2$  coated glass and (b) a standard glass in the outdoor chamber. The vertical line indicates the start of the irradiation.

tion, suggesting that it is formed from NO photocatalytic oxidation and then converted into HNO<sub>3</sub> and HNO<sub>2</sub> at the surface.  $^{14-17,22}$  At the same time, a significant accumulation of ozone is observed. In agreement with previous studies,  $^{14-16}$  HNO<sub>2</sub> production is enhanced under irradiation in the presence of TiO<sub>2</sub> (Figure 1). However, when a standard glass (i.e., TiO<sub>2</sub> free) is analyzed in both chambers, no O<sub>3</sub> formation is observed (Figures 1b and 2b). The NO<sub>2</sub> and NO concentration—time profiles obtained in the absence of glass samples are similar to those observed in the presence of standard glasses, with no evidence of any light effect (Figures 2b and S4). These results clearly suggest that O<sub>3</sub> formation cannot be explained by the gas phase chemistry occurring in the chambers. The differences between the O<sub>3</sub> profiles from the blank experiments and the coated glass indicate that TiO<sub>2</sub> should be involved in the reaction mechanism leading to O<sub>3</sub> formation probably via new surface reactions.

To further investigate the reason for  $O_3$  production, a second type of experiment has been carried out using a flow tube reactor, where only air or  $N_2$  was present in the gas phase. It is well-known

<sup>†</sup> IRCELYON, Université Lyon 1.

<sup>&</sup>lt;sup>‡</sup> LISA, Universités Paris Est Créteil et Paris Diderot.

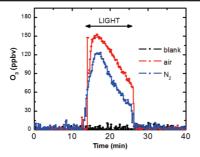


Figure 3. Effect of light (8 near-UV emitting lamps in the 300-420 nm wavelength range) on a TiO<sub>2</sub>/KNO<sub>3</sub> (50% w/w) film using synthetic air and pure N<sub>2</sub> as carriers. The same blank signal was given by an empty tube and by a tube with a KNO3 deposit using both carriers.

that nitrate anions are formed as a consequence of the photocatalytic oxidation of NO<sub>2</sub> on UV-illuminated TiO<sub>2</sub> surfaces. 9,18-22 Therefore a film of TiO<sub>2</sub>/KNO<sub>3</sub> 50% w/w has been exposed to near-UV irradiation (300-420 nm) using synthetic air or pure N<sub>2</sub> as a carrier gas with 30% RH under atmospheric pressure and at  $T = 298 \pm 1$ 

As described previously, a renoxification process occurs on illuminated TiO<sub>2</sub> films mixed with nitrate.<sup>23</sup> In contrast with the mechanism proposed by Grassian and co-workers<sup>24,25</sup> for the photochemistry of adsorbed nitrate on alumina, control experiments indicate that nitrate photolysis is negligible under the experimental conditions (Figure 3). NO<sub>3</sub> reduction by conduction band electrons may lead to the release of NO<sub>x</sub>, but it does not explain O<sub>3</sub> formation.<sup>27</sup> An alternative surface chemical pathway would involve the photochemistry of the NO<sub>3</sub> radical, produced by a charge exchange reaction between the nitrate anion and the solid surface, followed by photolysis of the radical (occurring at longer wavelength compared to the anion)23 according to

$$TiO_2 + h\nu \rightarrow h_{vb}^+ + e_{cb}^- \tag{1}$$

$$O_2 + e_{cb}^- \rightarrow O_2^{\bullet -} \tag{2}$$

$$NO_3^- + h_{vb}^+ \rightarrow NO_3^{\bullet} \tag{3}$$

$$NO_3^{\bullet} + h\nu \rightarrow NO_2 + O^{\bullet}$$
 (4)

$$NO_3^{\bullet} + h\nu \rightarrow NO + O_2 \tag{5}$$

$$O^{\bullet} + O_2 + M \rightarrow O_3 + M \tag{6}$$

TiO<sub>2</sub> band gap excitation (eq 1) produces excited-state conduction-band electrons and valence-band holes, which can then react with electron acceptors and electron donors adsorbed onto the semiconductor surface. According to Marcus theory, 28 the activation energy  $(\Delta G^{\neq})$  for the oxidation of nitrate anion into nitrate radical by the holes can be calculated by eq 8:

$$\Delta G^{\neq} = \frac{\lambda}{4} \left( 1 - \frac{F(E_{\text{vb}} - E_{\text{NO}_3^{\bullet}/\text{NO}_3^{-}})}{\lambda} \right)^2 \tag{7}$$

where  $\lambda$  is the reorganization energy necessary to transform the nuclear configurations in the reactant and the solvent to those on the product state;  $E_{\rm vb} = 3.25 - 0.06 \rm pH~V$  (vs NHE) is the valence band edge potential<sup>29</sup> in TiO<sub>2</sub> and E = 2.3-2.5 V (vs NHE) is the redox potential range for the NO<sub>3</sub>/NO<sub>3</sub> couple.<sup>30,31</sup> Assuming that the reorganization energy accounts for only the solvent contribution and that it is approximately 0.5 eV,<sup>29</sup> then  $\Delta G^{\neq}$  approaches zero, so h<sub>vb</sub> can directly oxidize NO<sub>3</sub>.

New surface reactions occurring on illuminated TiO2 surfaces are discussed, for the first time, as a possible source of O<sub>3</sub>. Although O<sub>3</sub> has been recently proven to decompose on illuminated TiO<sub>2</sub> surfaces, 32 its formation is observed when TiO2 treated surfaces are exposed to NO<sub>x</sub> under illumination. Charge transfer reactions are taking place at the surface of TiO<sub>2</sub>, producing nitrate radicals from the corresponding anions. The photochemistry of the NO<sub>3</sub> radical leads to O<sub>3</sub> formation, enhancing the oxidizing power of these surfaces.

Acknowledgment. We acknowledge the French Ministry for Environment and Ademe for support from the Primequal2 grant PhotoBat and the ANR for support from the NeoRad grant. This work was also supported by the European Community within the 7th Framework Program, through the EUROCHAMP-2 project.

Supporting Information Available: Experimental procedures, Figures S1-S4, and references. This material is available free of charge via the Internet at http://pubs.acs.org.

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JA1018755